

# Intersubband Transition in GaN/AIN Multiple Quantum Wells for Optical Switches

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### Outline

- 1. Background
  - > Very fast relaxation in GaN ISBT
  - > Effect of built-in field
- 2. Verification of fast absorption recovery and estimation of intensity of saturable absorption
- 3. Fabrication and characterization of optical switches
  - >Optical gate within 1 ps
  - >Switching with extinction ratio of 10 dB
- 4. Issues to be resolved
  - >Slow decay
  - >High switching energy
- 5. Schemes for further improvement

# **Optical switching by utilizing ISBT**



\* Polarization dependency: Absorption occurs only for TM-polarization



#### **ISBT relaxation time**

•2
$$\rightarrow$$
1 ISB scattering  
(after Ridley)  $W_{21} = \frac{1}{2} W_0 \left(\frac{\hbar\omega_{LO}}{E_1}\right)^{1/2} \left[\frac{1}{4 - (\hbar\omega_{LO}/E_1)} + \frac{1}{12 - (\hbar\omega_{LO}/E_1)}\right]$   
 $E_1$ : energy of 1st subbnad

material parameters	GaN	InGaAs	CdS
effective mass (m <sub>0</sub> ) m*	0.2	0.042	0.19
static dielectric constant $\varepsilon_s$	9.5	14.1	10.3
optical dielectric constant $\epsilon_{\infty}$	5.4	11.6	5.2
LO phonon energy (meV) $\hbar\omega_{LO}$	88	36	38
$W_{0} = \frac{e^{2}}{4\pi\hbar} \left(\frac{2m^{*}\omega_{LO}}{\hbar}\right) \frac{1}{2} \left[\frac{1}{\varepsilon_{\infty}} - \frac{1}{\varepsilon_{s}}\right]  (p^{-1}s^{-1})$	121	6.7	90

GaN has the largest ISB scattering rate.



#### **Wavelength dependence of relaxation time**



Our proposal: Utilizing ISBT in GaN QWs for ultrafast optical devices



#### **Potential applications**







### **Transition wavelength & well thickness**



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Year	Group	λ <b>(μm)</b>	Growth
1997	UCSB	2.9 μm	MOCVD
1998	Toshiba	2.9 μm	MOCVD
2000	Lucent	1.4 μm	MBE
2002	Sophia U.	1.08 μm	MBE
2002	Toshiba	1.33 μm	MBE
2003	U. Tokyo	<b>2.4</b> μm	MOCVD

#### Field strength in GaN wells

- ~ 2 MV/cm in GaN/Al<sub>0.65</sub>Ga<sub>0.35</sub>N
- > 5 MV/cm in GaN/AIN
- Piezoelectric effect
- Spontaneous polarization

### Features of ISBT in GaN QWs



Input pulse energy (pJ)

10<sup>2</sup>

# Early studies on GaN ISBT (~2002)

- Feasibility study of optical switch utilizing ISBT in GaN
  - 1997 N. Suzuki et al. (Toshiba)
- Realization of GaN-ISBT at MIR
  - 1997 R. Kehl Sink et al. (UCSB)
  - 1998 N. lizuka et al. (Toshiba)
- Realization of GaN-ISBT at NIR
  - 2000 C. Gmachl et al. (Bell Labs)
  - 2002 N. lizuka et al. (Toshiba)
  - 2002 K. Kishino et al. (Sophia U.) @ 1.08  $\mu$ m: shortest wavelength
- Verification of fast absorption recovery
  - 2000 N. lizuka et al. (Toshiba) @ 4.5  $\mu m$
  - 2001 C. Gmachl et al. (Bell Labs.) @ 1.55  $\mu m$



#### Recent studies on GaN ISBT (2002~)

#### Intensive studies on the nonlinearity

- 2002 ~ 2003 Bell labs
- 2004 ~ 2005 J. Hamazaki et al. (Sophia U.)

#### Realization of GaN-ISBT at NIR by MOCVD

- 2004 I. Waki et al. (U. Tokyo) @ 2.4 μm
- 2006 S. Nicolay et al. (EPFL) @ 2.0 μm
- 2007 (ITQW07) M. Halsall et al. (U. Manchester) @ 1.2 1.7  $\mu m$
- □ Light emission
  - 2007 (ITQW07) L. Nevou et al. (U. Paris-Sud) @ 1.3 2  $\mu m,$  SHG @ 1  $\mu m$

#### Detector

- 2003 D. Hofstetter et al. (U. Neuchâtel)
- 2006 (ITQW07) E. A. DeCuir et al. (U. Arkansas)
- 2007 (ITQW07) A.Vardi et al. (Technion-Israel Inst. Tech.)
- **D** Switching / modulation
  - 2004 N. lizuka et al. (Toshiba): XAM (Cross absorption modulation)
  - 2006 E. Baumann et al. (U. Neuchâtel): E-O modulator
  - 2007 (ITQW07) N. Kheidrodin et al. (U. Paris-Sud): E-A modulator
  - 2007 Y. Li et al. (Boston U.): Saturable absorption

#### Dots

- 2003 Kh. Mousmanis et al. (U. Paris-Sud)
- 2006 G. Guillot et al. (CEA-Grenoble)
- 2007 (ITQW07) L. Nevou et al. (U. Paris-Sud)
- 2007 (ITQW07) G. Bahir et al. (Technion-Israel Inst. Tech.)

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#### **Sub-picosecond absorption recovery**





#### **Estimation of saturation intensity**





#### **Comparison between calculation and experiment**





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#### **Structure of gate switch**





#### **Setup for measurements**



#### **Gate switch operation**



#### **Generation of four serial pulses**





#### **Response for serial pulses**



Leading Innovation >>>

**ITQW 2007 Ambleside, UK** 20

#### **Absorption saturation and extinction ratio**



#### **Reduction of excess propagation loss**



lizuka et al., JAP, vol. 99 (2006)



#### **Improved device structure**







#### **Absorption saturations**



of 1.55 μm (100 pJ) and 1.7 μm (150 pJ)

lizuka et al., Optics Express, vol. 13 (2005)



#### Improvement of gate switch operation





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#### Issues to be resolved - (1) slow decay





#### **Exchange of wavelengths for control and signal**



Exchange of wavelength resulted in shortening the time constant of the slow component from 2.2 ps to 0.7 ps.

lizuka et al., IEEE JQE, vol. 42 (2006)

### **Our proposed model**

#### Proposed model:

The barrier thickness was as thin as 1.5 nm and the number of wells was only two. Then, carriers in the wells may diffuse (tunnel) out to the undelying GaN layer.



If parameters of QW structure, e. g. number of wells, barrier thickness and doping, are optimized, the slow decay component can be suppressed.

### Issues - (2) switching energy



N. lizuka et al., J Quantum Electron. **42**, 765(2006) T. Shimoyama et al., OFC2003 proceedings R. Akimoto et al., phys. stat. solidi **243**, 805(2006)

Switching energy of GaN ISBT is higher than those of other materials

#### Issues - (2) switching energy

150 pJ/pulse  $\Rightarrow$  150 W for 1 Tb/s:Too high for practical use.



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#### **Expected improvement - simulation -**





According to the simulation,

the switching energy can be reduced to ~1 pJ, when

the excess propagation loss is completely suppressed,

the coupling loss decreases to 1 dB/facet, and

the device size is submicron.



#### **Proposed structure (plan)**





#### **AIN-based waveguide I**



#### **AIN-based waveguide II**



Kumtornkittikul et al., Jpn. J. Appl. Phys, vol. 46 (2007)

#### SiN cladding



As expected: Smooth facet was obtained for SiN cladding. No excess polarization-dependent loss was observed.

Shimizu et al., JSAP Annual meeting (2007)



#### **Possibility of application of quantum dots**



By control of relaxation time, switching energy can be adjusted.

Although growth of small-diameter QDs with good uniformity is extremely difficult, the application of the dots to switching devices is very attractive.



#### **Pump-probe measurement for large dots**

#### 60 QD layers (large diameter)





### Summary -I-

- Applications of ISBTs in GaN QWs/QDs to optical signal processing were discussed.
- Sub-picosecond absorption recovery was verified.
- > Saturation intensity was estimated to be 4 15 W/ $\mu$ m<sup>2</sup>
- All-optical switching was demonstrated for serial pulses with an pulse interval of as short as 0. 67 ps.
- Switching extinction ratio of greater than 10 dB was achieved.
- Gate width of as narrow as 230 fs was realized.



### Summary -II-

- It was pointed out that thin barriers brought about a slow absorption recovery and that the switching energy was too high for practical use.
- For the issues to be resolved, utilizing AIN lower cladding and SiN upper cladding was proposed.
- Potential of quantum dots was pointed out and results of preliminary experiment were shown.
- In conclusion, ISBTs in GaN QWs/QDs are promising with respect to realizing optical switches and signal processing devices.

